Docket No.: YOR920030603US1

## IN THE SPECIFICATION:

Please amend the paragraph beginning at page 8 line 10 as follows:

As shown in the following figures, in a conventional Field Effect

Transformer Iransistor (FEI) setting, a gated diode can be formed by the source and the gate of a three terminal FEI device (either n-type or p-type), with the drain floating (e.g., disconnected or nonexistent), as shown in (for example) FIGS 1B, 4B, 6 and 8. Sometimes the source and drain of such a FEI can be connected together at the same potential an and may be viewed as two gated diodes connected in parallel, as shown in (for example) FIGS 2B, 5B, 7 and 9. In this disclosure, these two situations are used interchangeably. And without specifying explicitly, a gated diode is referred to just the first basic form, only a source and a gate of a semiconductor device.